Charge transfer and interfacial magnetism in (LaNiO₃)_n/(LaMnO₃)₂ superlattices

J. Hoffman,^{1,*} I. C. Tung,^{2,3} B. B. Nelson-Cheeseman,¹ M. Liu,⁴ J. W. Freeland,³ and A. Bhattacharya^{1,4,†}

¹Materials Science Division, Argonne National Laboratory, Argonne, Illinois 60439, USA

²Department of Materials Science and Engineering, Northwestern University, Evanston, Illinois 60208, USA

³Advanced Photon Source, Argonne National Laboratory, Argonne, Illinois 60439, USA

⁴Nanoscience and Technology Division, Argonne National Laboratory, Argonne, Illinois 60439, USA

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 $(LaNiO_3)_n/(LaMnO_3)_2$ superlattices were grown using ozone-assisted molecular beam epitaxy, where $LaNiO_3$ is a paramagnetic metal and $LaMnO_3$ is an antiferromagnetic insulator. The superlattices exhibit excellent crystallinity and interfacial roughness of less than one unit cell. X-ray spectroscopy and dichroism measurements indicate that electrons are transferred from the $LaMnO_3$ to the $LaNiO_3$, inducing magnetism in $LaNiO_3$. Magnetotransport measurements reveal a transition from metallic to insulating behavior as the $LaNiO_3$ layer thickness is reduced from five to two unit cells and suggest an inhomogeneous magnetic structure within $LaNiO_3$.

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I. INTRODUCTION

In recent years, there has been a great amount of interest in the novel electronic and magnetic states that emerge at interfaces between dissimilar complex oxide materials.¹ In the most commonly studied systems, these new behaviors arise as a result of interfacial charge redistribution and a resulting reconstruction of the orbital and spin degrees of freedom. The interfacial charge redistribution can arise in several ways. For example, at the widely studied LaAlO₃ (polar)/SrTiO₃ (nonpolar) interface, this may result from a polar discontinuity.^{2–4} Charge redistribution may also result from differences in chemical potential across an interface, as in LaTiO₃/SrTiO₃.⁵ In magnetic systems, such as shortperiod LaMnO₃/SrMnO₃ superlattices, charge redistribution between neighboring Mn³⁺/Mn⁴⁺ sites can give rise to intermediate valency and a ferromagnetic, metallic ground state at the interface. $^{6-8}$ Interfacial magnetism is linked to the charge state and bonding between the nearest-neighbor B-site transition metal cations, and may therefore be very sensitive to the details of the structure.^{9,10} Thus creating tailored exchange interactions in oxide heterostructures requires precise control and understanding of the interface.

In this work, we examine the role of charge transfer in a series of digital superlattices that combine metallic LaNiO₃ (Ni^{3+}) with insulating antiferromagnetic LaMnO₃ (Mn³⁺). In this model system, each BO_2 atomic plane (B = Mn, Ni) is sandwiched between two *identical* AO (LaO) layers, thus ruling out intermixing of the A-site cation, which has been shown to lead to inadvertent doping.¹¹ Through x-ray spectroscopy measurements we show the Mn to be in a 4+ oxidation state, while that of Ni is intermediate between 2+ and 3+, showing conclusively the presence of a charge transfer at the [001] LaNiO₃/LaMnO₃ interface. The superlattices are found to have a net magnetic moment, with the magnetism residing on both the Mn and Ni sites. We also observe a transition from metallic transport to insulating behavior as the thickness of the LNO layer is reduced below four unit cells. These results, combined with magnetotransport measurements, point to the existence of a metallic state with inhomogeneous magnetism in LaNiO₃ with a mixture of Ni valence states.

II. MATERIALS AND EXPERIMENTAL

LaMnO₃ (LMO) has been extensively investigated as the parent compound of the prototypical perovskite colossal mag-netoresistive (CMR) oxides.^{12,13} In stoichiometric bulk LMO with $t_{2g}^3 e_g^1$ occupancy, a cooperative Jahn-Teller distortion lifts the degeneracy of the half-filled e_g band, producing an orbitally-ordered A-type antiferromagnetic insulating ground state.¹⁴ In thin films, however, LMO often exhibits ferromagnetism with a Curie temperature of ~ 150 K and a saturation moment close to 4 μ_B/Mn due to cation deficiency and strain.^{15–17} The LMO investigated here shows insulating behavior with a gap of ~185 meV, a low saturation magnetization $(M_s < 0.6 \mu_B/Mn)$, and high coercivity, consistent with a weakly canted antiferromagnetic spin arrangement. LaNiO₃ (LNO), on the other hand, is a paramagnetic metal where the Ni³⁺ ion adopts a low spin, orbitally degenerate $t_{2g}^6 e_g^1$ electronic configuration. Strong mixing between the d^7 and $d^{8}L$ (L denotes a ligand hole on the oxygen) configurations is expected, as LNO is significantly more covalent than divalent nickel compounds. The introduction of Ni²⁺ through oxygen deficiencies¹⁸ or Ce-doping¹⁹ has previously been shown to increase the resistivity of LNO and induce a transition to an insulating state. Under our growth conditions, the resistivity of an 80-unit-cell-thick LNO film showed metallic behavior, with $\rho(T = 5K) = 35 \ \mu\Omega$ cm, comparable to the lowest value for stoichiometric bulk samples.^{20,21}

Epitaxial [(LaNiO₃)_n/(LaMnO₃)₂]_m superlattices with $2 \le n \le 5$ unit cells were grown on (001) TiO₂-terminated SrTiO₃ single-crystal substrates using ozone assisted molecular beam epitaxy (MBE). The total heterostructure thickness was kept constant at ~80 unit cells (~30 nm) by adjusting the stacking periodicity *m*. Elemental materials were evaporated sequentially from effusion cells using a block-by-block technique described previously^{22,23} under an O₃ partial pressure of 2×10^{-6} Torr, with the substrate maintained at 690 °C. After growth, x-ray reflectivity (XRR) was used to confirm the thickness and determine the interfacial and surface roughnesses; the crystal structure and epitaxy were investigated with x-ray diffraction (XRD). The in-plane resistivity was measured as a function of temperature in a four-point geometry for 2 K $\le T \le 300$ K, while the Hall coefficient was measured



FIG. 1. (Color online) X-ray reflectivity (a) and high-resolution x-ray diffraction (b) scans for a series of $[(\text{LaNiO}_3)_n/(\text{LaMnO}_3)_2]_m$ superlattices on SrTiO₃. The *c*-axis lattice parameters are found to be 0.3847, 0.3824, 0.3823, and 0.3816 nm for n = 2,3,4,5, respectively.

using the Van der Pauw method in fields of up to 9 T. Measurements of the net sample magnetization were carried out as a function of temperature and magnetic field using a superconducting quantum interference device (SQUID) magnetometer, while cation specific magnetic properties were investigated using x-ray magnetic circular dichroism (XMCD). To determine the electronic properties, the superlattices were examined with x-ray absorption spectroscopy (XAS) in the soft x-ray regime at beamline 4-ID-C of the Advanced Photon Source (Argonne National Laboratory). The spectra were measured in both the surface-sensitive total electron yield and bulk-sensitive fluorescence yield modes and were aligned to a NiO (Ni²⁺) standard measured simultaneously with the superlattice samples.

III. RESULTS

In order to obtain the intrinsic properties of the LMO/LNO interfaces, we require these to be atomically sharp with precise control of the stacking periodicity. The thickness and lattice parameters of our samples were determined by x-ray reflectivity and high-resolution x-ray diffraction, as shown in Figs. 1(a) and 1(b), respectively. Pronounced Bragg reflections indicate the interfaces are abrupt, as confirmed by fitting to the reflectivity curves using the Parratt formalism, which also showed the superlattice periods to typically be within 1% of the nominal thicknesses. We observe a "double-peak" structure in the XRR scan for the n = 4 sample, where the superlattice density modulation is not an exact integer number of unit cells, and for this sample estimate the error in stacking periodicity to be around 3%. The average c-axis lattice constant is obtained from θ -2 θ scans performed around the (002) reflection as shown in Fig. 1(b) and is found to decrease monotonically with increasing LNO thickness from 0.385 nm for n = 2 to 0.382 nm when $n = 5^{24}$ in contrast with $(\text{LaNiO}_3)_n/(\text{SrMnO}_3)_2$ superlattices, where the largest out-of-plane lattice parameter was found for n = 4.22 The in-plane lattice parameters are determined by measurements of the (103) and (013) reflections and reveal that the superlattices are coherently clamped to the underlying SrTiO₃ substrate.



FIG. 2. (Color online) (a) Temperature dependence of the magnetization for $[(LaNiO_3)_n/(LaMnO_3)_2]_m$ superlattices with n = 2-5 and 80-unit-cell-thick films of LMO and LNO. Solid and open symbols show field-cooled and zero-field-cooled measurements, respectively. The field is applied in the plane of the film along the [100] direction. (b) Variation with number of LNO layers of the remanent magnetization (open symbols) and saturation magnetization (filled symbols). (c) Coercive field variation with number of LNO layers.

Figure 2(a) shows the temperature dependence of the magnetization of the four superlattices in addition to LMO and LNO films. The magnetization was measured while warming the samples in a field of 500 Oe applied in the plane of the film after field cooling in 500 Oe (solid symbols) and zero-field cooling (open symbols). On lowering the temperature, all of the samples except the LNO film, exhibit a rise in magnetization below a nominal transition temperature $T_C \sim 150$ K, corresponding to the onset of magnetic order. From hysteresis loops measured along the [100] direction at 5 K (not shown), we determine the remanent and saturation magnetizations [Fig. 2(b)], which show only weak variation for $2 \leq n \leq 5$. The coercive field displayed a systematic reduction with increasing n, as shown in Fig. 2(c). The small saturation magnetization (M_s < 0.6 μ_B /Mn) and high coercivity (\sim 5 000 Oe) of the pure LMO film are consistent with a weakly canted antiferromagnet ground state.

To probe the microscopic origins of the observed metalinsulator transition and magnetic ordering, we carried out both x-ray absorption spectroscopy (XAS) and x-ray magnetic circular dichroism (XMCD) measurements near the Mn and Ni $L_{2,3}$ absorption edges. Measurements were performed in fields of up to 5 T applied in the plane of the sample. Both bulk-sensitive fluorescence yield and surface-sensitive total electron yield configurations were found to give similar results. XAS spectra measured at T = 15 K are shown in Figs. 3(a) and 3(b) for the superlattices with n = 2 and 4, along with spectra



FIG. 3. (Color online) (a) Mn L₃ and (b) Ni L₃ XAS and XMCD spectra for $[(\text{LaNiO}_3)_2/(\text{LaMnO}_3)_2]_{20}$ and $[(\text{LaNiO}_3)_4/(\text{LaMnO}_3)_2]_{13}$ superlattices. Mn³⁺ and Mn⁴⁺ references adapted from Ref. 25. (c) and (d) Cation-resolved magnetization as a function of field for the superlattices with n = 2 and 4, along with average magnetization (weighted by concentration of Mn and Ni) and magnetization obtained by SQUID magnetometry.

for Mn³⁺ (LaMnO₃) and Mn⁴⁺ (La_{0.1}Sr_{0.9}MnO₃) from Ref. 25 and measured reference spectra for Ni²⁺ (NiO) and Ni³⁺ (LaNiO₃). The peak at 849.5 eV in Fig. 3(b) is due to the La M_4 transition. We find that for both the n = 2 and 4 superlattices the valence of Mn is nearly Mn⁴⁺, unlike in bulk LMO, where Mn is in the 3+ oxidation state. The Ni valence is close to Ni²⁺ in the n = 2 structure, while signatures of both Ni²⁺ and Ni³⁺ are found in the superlattice with 4 layers of LNO. The Ni L_3 -edge spectra of the n = 4 superlattice is similar to that reported for bulk *R*NiO₃ materials below the metal-insulator transition temperature²⁶ and for short-period LaNiO₃/LaAlO₃ superlattices,^{27,28} where the two-peak feature was attributed to the formation of charge-ordered states. In our samples, we are unable to distinguish this scenario from a simple mixed valence picture without charge ordering. The results suggest that each Mn donates one electron to a nearby Ni cation at the interface, as in the double perovskite La₂NiMnO₆.²⁹ The Ni²⁺ is expected to have a doubly-degenerate, highspin (S = 1) e_g manifold, with antiferromagnetic coupling to neighboring Ni²⁺ cations, as in La₂NiO₄. The competing exchange interactions at the interface may result in a frustrated magnetic state, as recently proposed to explain the exchange-bias effects observed in La_{0.75}Sr_{0.25}MnO₃/LaNiO₃ superlattices.³⁰

In Figs. 3(c) and 3(d), we show the net magnetization estimated for the Mn and Ni cations in the superlattices with n = 2 and n = 4, as the magnetic field is varied from 0.1 to 5 T, with the temperature held constant at 15 K^{31} We find that the saturation Mn magnetization in both samples is enhanced compared to the pure LMO film [see Fig. 2(b)], and the measured value of $\sim 2 \mu_B/Mn$ is inconsistent with purely antiferromagnetic ordering of the Mn⁴⁺ cations. We note that Mn^{4+} is expected to have an empty e_g manifold (as in CaMnO₃), thus quenching the Jahn-Teller distortion and giving rise to G-type antiferromagnetic ordering. The large magnetization that we observe may then occur by several mechanisms. First, recent experimental work has shown that weak ferromagnetism can arise through phase separation in lightly electron-doped CaMnO₃.³² Second, tensile strain, such as from coherent growth on SrTiO₃ substrates, has been shown theoretically to favor an A-type antiferromagnetic arrangement that may be susceptible to canting, leading to a net magnetization.³³

We also find a net moment on the Ni cations, in agreement with Ref. 30, which we estimate to be 0.35 μ_B/Ni at 5 T for both n = 2 and 4. From the shapes of the Mn and Ni $L_{2,3}$ -edge spectra, we determine that the net moment of the LMO and LNO layers are coupled ferromagnetically. To check the internal consistency of our XMCD magnetization estimates, we have computed the net magnetization of the superlattices by weighting the magnetization of the individual cations, as shown by the solid squares in Figs. 3(c) and 3(d). We find good agreement between the net magnetizations obtained from XMCD measurements and from SQUID magnetometry measurements [open circles in Figs. 3(c) and 3(d)].³⁴

Figure 4(a) shows the variation of the resistivity of the LNO/LMO superlattices and LNO and LMO thin films as a function of temperature. As shown in Fig. 4(b), the resistivity of an 80-unit-cell LMO film shows thermally activated behavior, $\rho = \rho_{\infty} \exp(E_A/k_BT)$ with an activation energy, $E_A = 185$ meV. The resistivity of the n = 2 superlattice is well described by a two-dimensional variable-range hopping (VRH) model [Fig. 4(c)] given by

$$\rho = \rho_{\infty} \exp[(T_0/T)^{1/3}],$$
(1)

where T_0 is a characteristic temperature related to the density of states at the Fermi energy, $N(\varepsilon_F)$, and the localization length ξ by³⁵

$$T_0 \approx \frac{13.8}{k_B N(\varepsilon_F) \xi^2}.$$
 (2)

Two-dimensional VRH has previously been observed in ultrathin (five unit cell) LNO films³⁶ and $(\text{LaNiO}_3)_2/(\text{SrMnO}_3)_2$ superlattices.²² In the n = 2 sample, $T_0 \approx 1.31 \times 10^6$ K and



FIG. 4. (Color online) Magnetotransport behavior of $[(\text{LaNiO}_3)_n/(\text{LaMnO}_3)_2]_m$ superlattices, $2 \le n \le 5$. (a) Temperature dependence of longitudinal resistivity. The arrows indicate positions of the resistivity minima at T = 90 K (n = 4) and T = 30 K (n = 5). (b) Resistivity of a pure LaMnO_3 film with a fit to thermally activated transport. (c) Fit to 2D variable-range hopping for n = 2 for 60 K $\le T \le 300$ K. (d) Magnetoresistance ratio (MRR) of n = 3, 4, and 5 superlattices at T = 5 K with the field applied normal to the film.

the mean hopping energy $\Delta E \approx 0.28k_B T_0^{1/3} T^{2/3}$, exceeds $k_B T$ over the entire temperature range studied (60 K $\leq T \leq 300$ K). The density of states in bulk LNO is $\sim 1.1 \times 10^{29}$ eV⁻¹ m⁻³,³⁷ from which we estimate $\xi \sim 0.07$ nm. This localization length is incompatible with traditional theories of variable-range hopping where the localization length must be greater than the Ni-Ni distance and this may be due to the fact that the density of states we use is largely overestimated, consistent with our observation of Ni²⁺ in this sample [see Fig. 3(b)]. This is similar to previous reports on hole-doped manganites,³⁸ where a reduced $N(\varepsilon_F)$ was proposed to explain the insulating behavior. This may occur due to the formation of a pseudogap.³⁹

In previous studies of LaNiO₃/LaAlO₃,^{27,40} LaNiO₃/SrTiO₃,⁴¹ and LaNiO₃/SrMnO₃²² superlattices, a transition from metallic to insulating behavior was observed as the thickness of the LNO layer was reduced below three unit cells. The fact that this transition occurs at the same thickness in the LNO/LMO superlattices studied here is surprising, as the average valence of the nickelate layer is lower due to charge transfer observed at the LMO/LNO interface.

To probe the origin of the thickness dependent metal to insulator transition, we performed magnetotransport measurements on the superlattices. Figure 4(d) shows the magnetic field dependence of the magnetoresistance ratio (MRR) at T = 5 K for the superlattices with n = 3 to 5. (MRR is defined as [R(H) - R(0)]/R(0).) All of the superlattices show negative magnetoresistance, which is largest in the n = 3sample, and decreases in the metallic samples. The orientation dependence of the resistance (anisotropic magnetoresistance or AMR) was investigated in the n = 4 superlattice by rotating the sample about the [100]-axis in a fixed field of 9 T (J is along the [100] crystallographic direction and is maintained perpendicular to the magnetic field). The resistance follows a $\cos^2 \theta$ dependence, where θ is the angle between the magnetic field and the normal to the film plane. This is consistent with the AMR of ferromagnetic conductors, and further evidence that the carriers in LNO are scattering off magnetic moments in the superlattice.

In order to elucidate the nature of transport in the superlattices, we have measured the transverse (Hall) resistivity. Empirically, for a ferromagnetic conductor this may be written as

$$\rho_{xy} = R_H B + R_S \mu_0 M, \tag{3}$$

where R_H is the ordinary Hall coefficient and R_S is the anomalous Hall coefficient. We determine R_H from the high-field (H > 4 T) slope of the antisymmetric transverse resistivity [i.e., $(\rho_{xy}(+H) - \rho_{xy}(-H))/2$], while the anomalous Hall resistivity, $\rho_{xy}^{AHE}(T) = R_S(T)\mu_0 M(T)$, is found by extrapolating the high-field slope to H = 0 T. Figure 5(a) shows R_H as a function of temperature for the metallic superlattices, where conduction is assumed to take place through the LNO layers only. All of the samples show a positive Hall coefficient, consistent with hole-type conduction and in quantitative agreement with ultrathin LNO films⁴² and mixed-valence $La_{2-x}Sr_xNiO_4$ samples.⁴³ R_H is found to decrease nonlinearly with increasing temperature, which may point to the presence of two carrier types with different mobilities, as suggested by recent band structure calculations of LNO⁴⁴. The strong temperature dependence of R_H has also been attributed to antiferromagnetic correlations in the metallic phase of systems on the verge of an insulator to metal transition, such as $V_{2-x}O_3$,⁴⁵ NiS_{2-x}Se_x,⁴⁶ and cuprate superconductors.^{47,48} Assuming the current is confined to the LNO layers, we estimate the carrier concentration at T = 5 K for the metallic superlattices within a single-band model and find $p \approx 6.5 \times 10^{21}$ cm⁻³ (0.38 holes per unit cell) and $p \approx 8.2 \times 10^{21} \text{cm}^{-3}$ (0.48 holes per unit cell) for samples with n = 4 and 5, respectively. These values agree well with the expected number of holes per LNO unit cell, assuming each Ni cation at an interface donates a single hole to the neighboring Mn atom.



FIG. 5. (Color online) (a) Ordinary Hall coefficient as a function of temperature for n = 4 and 5 superlattices. (b) Temperature dependence of the anomalous Hall resistivity for the n = 4 and 5 superlattices. (c) Linear variation of the anomalous Hall resistivity with in-plane magnetization.

As shown in Fig. 5(b), we observe a negative anomalous Hall resistivity in the n = 4 sample below the magnetic transition temperature $T_C \sim 150$ K. The magnitude of the measured anomalous Hall resistivity is comparable to that previously observed in other ferromagnetic perovskite oxide systems.^{49–52} In the n = 5 sample, however, ρ_{xy}^{AHE} vanishes, despite the similarity of the bulk magnetic properties of the two superlattices [see Figs. 2(b) and 2(c)]. This unexpected behavior suggests the possibility of a inhomogeneous magnetic structure within the LNO layer, as was recently predicted to exist in (111)-oriented LMO/LNO superlattices.¹⁷ In the n = 4sample, conduction occurs in sufficiently close proximity to a magnetic interface to enhance spin-dependent scattering effects, giving rise to the observed anomalous Hall resistivity, while in the n = 5 sample, conduction takes place away from the spin-polarized interface through the middle of the LNO layer. Furthermore, the superlattices considered here, in particular, those with low n, consist of dimensionally

confined nickelate layers with intermediate valency, as found in the two-dimensional layered perovskite $La_{2-x}Sr_xNiO_4$. Here, variation in the Ni oxidation state from Ni²⁺ (x = 0) to Ni³⁺ (x = 1) induce a series of changes in the electronic and magnetic ground state, with both stripe and checkerboard-type charge ordering/correlations observed at intermediate doping levels.⁴³

The anomalous Hall effect arises from the spin-orbit interaction in the presence of broken time-reversal symmetry.⁵³ In homogeneous magnetic systems, R_S is predicted to scale with the longitudinal resistivity: $R_S \propto \rho_{xx}^{\gamma}$, with $\gamma = 1$ for skew-scattering and $\gamma = 2$ for the quantum mechanical sidejump mechanism. In magnetically inhomogeneous systems, such as Co/Pt superlattices54 and granular Co-Ag,55 values of γ greater than 2 have been reported. We analyze the anomalous Hall effect in the n = 4 sample qualitatively by plotting in Fig. 5(c) $\rho_{rv}^{AHE}(T)$ as function of M(T), the in-plane magnetization of the superlattice measured in a field of 500 Oe after field cooling. The linear dependence between $\rho_{xy}^{AHE}(T)$ and M(T)suggests that R_S is a constant, independent of temperature. However, as shown in Fig. 4(a), ρ_{xx} of the n = 4 superlattice has a minimum at T = 90 K, ruling out a simple power law scaling relation between R_S and ρ_{xx} . A lack of scaling between R_S and ρ_{xx} has also been observed in colossal magnetoresistive manganites, where R_S is sharply peaked above the Curie temperature. This behavior is attributed to Berry phase effects arising from fluctuating noncollinear spin textures.⁵⁶ This is, however, in contrast to our samples, where R_S does not depend on temperature, which may be due to a frozen interfacial spin texture, though a quantitative model is lacking. Quantitative determination of R_S is beyond the scope of this paper, and requires knowledge of the LNO magnetization as functions of both applied field and temperature.

IV. CONCLUSIONS

In conclusion, detailed magnetotransport, magnetic, and spectroscopic measurements were carried out on atomically sharp [001] (LaNiO₃)_n/(LaMnO₃)₂ superlattices. We have unambiguous evidence of the transfer of electrons from Mn to Ni, and ferromagnetic coupling of the net magnetization on the Mn and Ni sites. As the LNO layer thickness increases, the average Ni valence changes from Ni²⁺ (n = 2) to Ni^{2.5+} (n = 4), and is accompanied by a transition from insulating behavior to metallic transport. Detailed magnetotransport measurements suggest the carriers in the LaNiO₃ layer scatter off the magnetiz Ni sites at the interface, and that the magnetization on the Ni is inhomogeneous. This work opens new avenues for the creation of artificial oxide heterostructures with tailored electronic and magnetic properties.

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[†]anand@anl.gov

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- 24 The out-of-plane lattice constants for 80-unit-cell-thick films of LNO and LMO grown on (001) SrTiO₃ substrates were measured and found to be 0.394 and 0.381 nm, respectively.
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